

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Heng Liu  
Assignee: BridgeLux, Inc.  
Title: Chemical Vapor Deposition Reactor  
Application No.: 10/727,746 Filing Date: December 3, 2003  
Examiner: Ram N. Kackar Group Art Unit: 1792  
Docket No.: M-15626-1D US Confirmation No.: 8880

Irvine, California  
August 22, 2008

Mail Stop : AF – EXPEDITED PROCEDURE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE TO FINAL OFFICE ACTION**

Dear Sir:

This communication is in response to the Final Office Action dated May 23,  
2008.

Claims begin on page 2.

Remarks begin on page 11.